

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant	:	Hada et al.
Appl. No.	:	10/557,694
Filed	:	November 22, 2005
For	:	RESIN FOR PHOTORESIST COMPOSITION, PHOTORESIST COMPOSITION AND METHOD FOR FORMING RESIST PATTERN
Examiner	:	Kelly, C.
Group Art Unit	:	1752

RESPONSE TO NOTICE OF NON-COMPLIANT AMENDMENT**Mail Stop Amendment**

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Notice of Non-Compliant Amendment mailed January 16, 2007, enclosed herewith is a revised preliminary amendment. The preliminary amendment filed on November 22, 2005, was considered non-compliant because the paragraph added at page 1 of the specification was underlined. The enclosed preliminary amendment is the same as the one submitted on November 22, 2005, except that the underlining in the added paragraph has been removed. Thus, no new matter has been added. This preliminary amendment is now compliant, and entry thereof is respectfully requested.

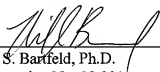
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No fee is believed to be due. However, please charge any necessary fees to Deposit Account 11-1410. Should there be any questions concerning this application, the Examiner is respectfully invited to contact the undersigned at the telephone number appearing below.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 1/25/07

By: 
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